



<b>Title</b>	<b>Deep level defects E1/E2 in n-type 6H silicon carbide induced by electron radiation and He-implantation</b>
<b>Author(s)</b>	<b>Ling, CC; Chen, XD; Fung, S; Beling, CD; Brauer, G; Anwand, W; Skorupa, W; Gong, M</b>
<b>Citation</b>	<b>Physics of Semiconductors, the 27th International Conference on the Physics of Semiconductors, Flagstaff, Arizona, 26-30 July 2004, v. 772 n. 1, p. 99-100</b>
<b>Issued Date</b>	<b>2005</b>
<b>URL</b>	<b><a href="http://hdl.handle.net/10722/47046">http://hdl.handle.net/10722/47046</a></b>
<b>Rights</b>	<b>Creative Commons: Attribution 3.0 Hong Kong License</b>

# Deep level defects E<sub>1</sub>/E<sub>2</sub> in n-type 6H silicon carbide induced by electron radiation and He-implantation

C. C. Ling<sup>1\*</sup>, X. D. Chen<sup>1</sup>, S. Fung<sup>1</sup>, C. D. Beling<sup>1</sup>, G. Brauer<sup>2</sup>, W. Anwand<sup>2</sup>,  
W. Skorupa<sup>2</sup>, M. Gong<sup>3</sup>

<sup>1</sup> Department of Physics, The University of Hong Kong, Pokfulam Road, Hong Kong, P. R. China

<sup>2</sup> Institut für Ionenstrahlphysik und Materialforschung, Forschungszentrum Rossendorf, Dresden, Germany

<sup>3</sup> Department of Physics, Sichuan University, Chengdu, P. R. China

**Abstract.** 6H-SiC samples subjected to He-implantation and e<sup>-</sup>-irradiation ( $E_e=0.2\text{MeV}-1.7\text{MeV}$ ) were investigated by deep level transient spectroscopy (DLTS). E<sub>1</sub>/E<sub>2</sub> were identified in the He-implanted and the e<sup>-</sup>-irradiated samples with  $E_e\geq 0.3\text{MeV}$ . Considering the minimum e<sup>-</sup> energy required to displace the atoms in the lattice, the E<sub>1</sub>/E<sub>2</sub> creation was related to the C-atom displacement. Similar to previous reports, the peak intensity and the capture cross sections of E<sub>1</sub>/E<sub>2</sub> anomalously varies from samples to samples. It was shown that these anomalies were due to the presence of a DLTS peak overlapping with the E<sub>1</sub>/E<sub>2</sub> signals.

## INTRODUCTION

E<sub>1</sub>/E<sub>2</sub> are the deep level defects commonly found in particle irradiated or ion implanted n-type 6H SiC but their microstructures are controversial.<sup>1-5</sup> As E<sub>1</sub> and E<sub>2</sub> are regarded as the same defect occupying the hexagonal and the cubic sites, the E<sub>1</sub> and the E<sub>2</sub> should have fixed peak intensity ratio and capture cross section. However, the E<sub>1</sub>:E<sub>2</sub> ratio and their capture cross sections were found to vary from samples to samples.<sup>2,3,6</sup> In the present study, we have investigated the E<sub>1</sub>/E<sub>2</sub> defects in n-type 6H-SiC induced by e<sup>-</sup>-irradiation and He-implantation.

## EXPERIMENTAL

Samples were from the n-type 6H-SiC (0001) epi layer (5μm,  $n=1\times 10^{16}\text{cm}^{-2}$ ) grown on the n<sup>+</sup>-type 6H-SiC substrate ( $n=8\times 10^{17}\text{cm}^{-2}$ ). E<sub>1</sub>/E<sub>2</sub> defects induced by He-implantation and e<sup>-</sup>-irradiation with different energies were studied. Electron irradiations were performed with  $E_e=0.2\text{MeV}$ , 0.3MeV and 1.7MeV. For the He-implantation, He ions were implanted with energies of 55keV, 210keV, 430keV, 665keV and

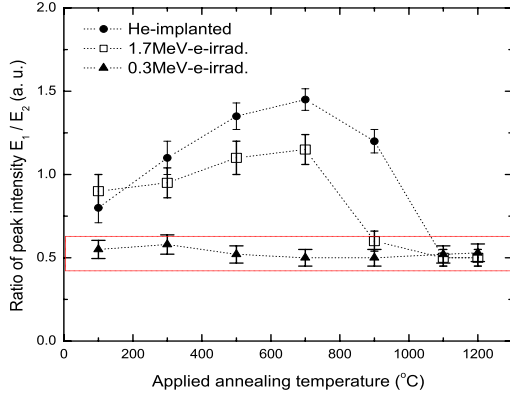
840keV (each with  $2\times 10^{11}\text{cm}^{-2}$ ) to create a 2μm box-shaped defected region.

## RESULTS AND ANALYSIS

The E<sub>1</sub>/E<sub>2</sub> peaks were clearly identified and were the dominant peaks in the e<sup>-</sup>-irradiated samples with electron energies  $E_e\geq 0.3\text{MeV}$  but could not be detected with  $E_e=0.2\text{MeV}$ . As the C atom has a lighter mass as compared to the Si atom, for a given e<sup>-</sup> energy, the maximum energy transferred from the electron to the C-atom is larger than that to the Si-atom. This implies the minimum e<sup>-</sup> irradiation energy required to displace the C-atom is less than that for the Si-atom. It was thus pointed out that the creation of the E<sub>1</sub>/E<sub>2</sub> by the electron irradiation was due to the displacement of the C-atom.<sup>1</sup> For the as-He-implanted sample, the E<sub>1</sub>/E<sub>2</sub> were not the most intense peaks, but their intensities grew with increasing annealing temperature before they annealed out.

The ratios of peak intensity E<sub>1</sub>:E<sub>2</sub> for the He-implanted, the 0.3MeV and the 1.7MeV e<sup>-</sup> irradiated samples as a function of the annealing temperature are shown in figure 1. The E<sub>1</sub>:E<sub>2</sub> ratio was constant at

\* E-mail of corresponding author: ccling@hku.hk

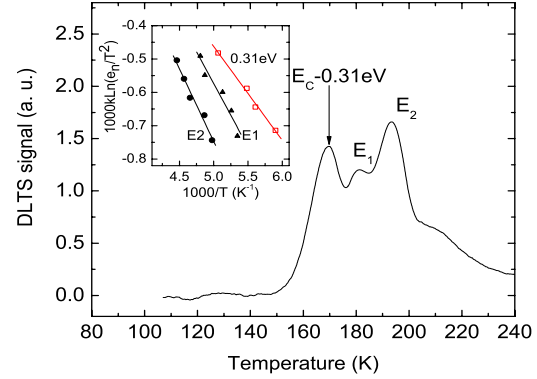


**FIGURE 2.**  $E_1:E_2$  ratio as a function of the annealing temperature.

about 0.5 for the 0.3MeV  $e^-$ -irradiated sample. In contrast, for the 1.7MeV  $e^-$ -irradiated and the He-implanted samples, the  $E_1:E_2$  ratio depends on the samples and on the annealing treatment. However, after the 1000°C annealing, the  $E_1:E_2$  ratio became constant at  $\sim 0.5$ , which is the similar value of the 0.3MeV  $e^-$ -irradiated sample.

$\sigma[E_1]$  and  $\sigma[E_2]$  were calculated by monitoring the increase of the peaks intensities as a function of the filling pulse width  $t_p$ , i.e.  $\Delta C \sim 1 - \exp(-\sigma n v / t_p)$ . For the 1.7MeV and the He-implanted samples, the  $E_2$  intensity increases with  $t_p$  at a faster rate than the  $E_1$ . The  $E_1$  defect thus has significantly larger value of  $\sigma$  than the  $E_2$  ( $\sigma[E_1]=8 \times 10^{14} \text{cm}^2$  and  $\sigma[E_2]=5 \times 10^{15} \text{cm}^2$  for the 1.7MeV  $e^-$ -irradiated sample). For the 0.3MeV  $e^-$ -irradiated sample, the  $E_1$  and the  $E_2$  intensities increase with  $t_p$  at similar rates, and this results in similar values of  $\sigma$  ( $\sigma[E_1]=3 \times 10^{15} \text{cm}^2$  and  $\sigma[E_2]=5 \times 10^{15} \text{cm}^2$ ). Moreover, after the 1000°C annealing, the discrepancy in values of  $\sigma[E_1]$  and  $\sigma[E_2]$  for the 1.7MeV  $e^-$ -irradiated and the He-implanted samples disappeared (with  $\sigma \sim 5 \times 10^{15} \text{cm}^2$ ).

To conclude our anomalous observation, the  $E_1:E_2$  peak ratio and the capture cross sections vary from samples to samples for the 1.7MeV  $e^-$ -irradiated and the He-implanted samples. However, these anomalies disappeared after the 1000°C annealing. For the 0.3MeV  $e^-$ -irradiated sample, these anomalies were never observed. One of the explanations is that there exists a defect peak overlapping with the  $E_1/E_2$  signals. This defect is only induced with 1.7MeV  $e^-$ -irradiation or He-implantation, but not with the 0.3MeV electron irradiation, and it anneals at 1000°C. The most direct evidence for the existence of such defect is shown in figure 2, for which this peak is separated from the  $E_1/E_2$  signals with  $V_r=-2\text{V}$ , rate window=136ms and



**FIGURE 2.** DLTS spectrum for the 900°C annealed He-implanted sample.

$t_p=100\mu\text{s}$ . The defect was found to be at  $E_C-0.31\text{eV}$  and  $\sigma=8 \times 10^{-14} \text{cm}^2$ .

## CONCLUSION

$E_1/E_2$  in  $e^-$ -irradiated and He-implanted 6H n-type SiC were studied by DLTS technique.. The  $E_1/E_2$  induction was related to the C-atom displacement in the lattice. Another defect peak ( $E_C-0.31\text{eV}$ ) was found to overlap with the  $E_1/E_2$  signals and this is possibly the cause of the peak intensity ratio and the capture cross section anomalies of the  $E_1/E_2$ .

## ACKNOWLEDGMENTS

This work was supported by the CERG, RGC (7085/01P and 7103/02P) and the national nature science of China (No.60076010).

## REFERENCES

1. Chen *et al*, Phys. Rev. Lett. **92**, 125504 (2004).
2. Hemmingsson *et al*, J. Appl. Phys. **84**, 704 (1998).
3. Kawasuso *et al*, J. Appl. Phys. **90**, 3377 (2001).
4. Aboelfotoh and Doyle, Phys. Rev. B **59**, 10823 (1999).
5. Pensl and Choyke, Physica B **185**, 264 (1993).
6. Gong *et al*, J. Appl. Phys. **85**, 7604 (1999).

Copyright of AIP Conference Proceedings is the property of American Institute of Physics. The copyright in an individual article may be maintained by the author in certain cases. Content may not be copied or emailed to multiple sites or posted to a listserv without the copyright holder's express written permission. However, users may print, download, or email articles for individual use.